



PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of:

BAILEY III et al.

Application No. 10/802,460

Filed: March 16, 2004

For: SYSTEM, METHOD AND APPARATUS
FOR SELF-CLEANING DRY ETCH

Group Art Unit: 2811

Examiner: Not Assigned

Atty. Docket No. LAM2P460

Date: June 17, 2004

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450 Alexandria, VA 22313-1450 on June 17, 2004.

Signed:

Melinda M. Ward

PRELIMINARY AMENDMENT

Commissioner for Patents
Alexandria, VA 22313-1450

Dear Sir:

Please enter the following preliminary Amendment to the above-identified application.

The preliminary amendment does not add any new matter.

In the Specification:

In the section entitled "Cross Reference to Related Applications" replace paragraph [1] with the following replacement paragraph [1]:

[1] This application is a continuation-in-part of and claims priority from U.S. Patent

Application No. 10/390,117 filed on March 14, 2003 and entitled "System, Method and Apparatus For Improved Global Dual-Damascene Planarization," which is incorporated herein by reference in its entirety. This application is also a continuation-in-part of and claims priority from U.S. Patent Application No. 10/390,520 filed on March 14, 2003 and entitled "System, Method and Apparatus For Improved Local Dual-Damascene Planarization," which is incorporated herein by reference in its entirety. This application is also a continuation-in-part of and claims priority from U.S. Patent

Application No. 10/744,355 (Atty Docket LAM2P448), filed on December 22, 2003
and entitled "Small Volume Process Chamber with Hot Inner Surfaces," which is
incorporated herein by reference in its entirety.

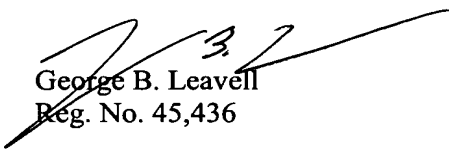


Marked Up Version:

[1] This application is a continuation-in-part of and claims priority from U.S. Patent Application No. 10/390,117 filed on March 14, 2003 and entitled "System, Method and Apparatus For Improved Global Dual-Damascene Planarization," which is incorporated herein by reference in its entirety. This application is also a continuation-in-part of and claims priority from U.S. Patent Application No. 10/390,520 filed on March 14, 2003 and entitled "System, Method and Apparatus For Improved Local Dual-Damascene Planarization," which is incorporated herein by reference in its entirety. This application is also a continuation-in-part of and claims priority from U.S. Patent Application No. [] 10/744,355 (Atty Docket LAM2P448), filed on December 22, 2003 and entitled "Small Volume Process Chamber with Hot Inner Surfaces," which is incorporated herein by reference in its entirety.

If the Examiner has any questions concerning the present response, the Examiner is kindly requested to contact the undersigned at (408) 749-6900, ext. 6923. Applicant believes no fees are due in connection with this filing, but in the event it is determined that any fees are due, then please charge such fees to Deposit Account No. 50-0805. (Order No. LAM2P460).

Respectfully submitted,
MARTINE & PENILLA, LLP


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